

CLAIMS

What is claimed is:

1. A saturable reflector apparatus comprising:
- a) a substrate having a first surface and a second surface; and
 - b) a reflector attached to one of the first and second surfaces, wherein the reflector includes a saturable absorber layer;
- wherein at least one of the first and second surfaces has been modified to enhance an etalon effect of the substrate.
2. The apparatus of claim 1 wherein the modified surface has been polished.
3. The apparatus of claim 1 wherein the modified surface includes a coating.
4. The apparatus of claim 3 wherein the coating includes a metallic or a dielectric material.
5. The apparatus of claim 1, further comprising means for tuning the etalon effect.
6. The apparatus of claim 5 wherein the tuning means comprise means for adjusting an optical thickness between the front and back surfaces.
7. The apparatus of claim 6 wherein the adjusting means comprises a heat transfer element thermally coupled to the substrate, wherein the heat transfer element is chosen from the group consisting of heater elements and cooling elements.

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8. The apparatus of claim 7, further comprising a temperature controller coupled to the heat transfer element.

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9. The apparatus of claim 1, wherein the reflector includes a Bragg stack, whereby the saturable reflector is a saturable Bragg reflector (SBR).

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10. The apparatus of claim 1 wherein the reflector includes a metal or dielectric film.

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11. The apparatus of claim 1, wherein the substrate is between about 100 microns and 1000 microns thick.

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8. A method for tuning a Saturable Reflector comprising the steps of:

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a) providing a substrate having a first surface and a second surface;
b) attaching a reflector with a saturable absorber layer to the first surface;
c) modifying at least one of the first and second surfaces to enhance an etalon effect of the substrate; and
d) using the etalon effect to control a spectrum of radiation reflected from the saturable reflector.

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10. The method of claim 9 wherein the modifying step comprises polishing at least one of the front and back surfaces to within a quarter wavelength of light that will be used with the SBR.

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11. The method of claim 9 wherein the modifying step comprises coating at least one of the front and back surfaces with a reflective coating.

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12. The method of claim ¹⁴11 wherein the coating includes a metallic or a dielectric material.

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13. The method of claim ¹²12, further comprising the step of tuning the etalon effect.

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14. The method of claim ¹⁶13 wherein the tuning step comprises adjusting an optical thickness between the first and second surfaces of the substrate.

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15. The method of claim ¹⁷14 wherein the thickness is adjusted by controlling a temperature of the substrate.

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16. The method of claim ¹⁸15, wherein the tuning adjusts a length of an optical pulse that is incident on the SBR.

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17. The method of claim ¹⁹16, wherein the tuning optimizes a relation between temporal and frequency domains of radiation incident on the SBR.

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18. The method of claim ²⁰17 wherein the tuning adjusts a distribution of optical power amongst two or more modes of radiation incident on the saturable reflector.

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19. A laser comprising:
a) an optical cavity;
b) a lasing medium disposed within the optical cavity;
c) a pump configured to provide pump radiation to the lasing medium; and
d) a saturable reflector optically coupled to the cavity, wherein the saturable reflector includes

- 8 i) a substrate having a first surface and a second
9 surface; and
10 ii) a reflector having a saturable absorber layer
11 attached to one of the front and back surfaces;
12 and
13 wherein at least one of the first and second surfaces
14 has been modified to enhance an etalon effect of the
15 substrate.

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The laser of claim ~~19~~ further comprising a non-linear medium disposed within the cavity.

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The laser of claim ~~20~~ wherein the nonlinear medium is a crystal containing a material chosen from the group consisting of Lithium Niobate (LiNbO_3), Lithium Tantalate (LiTaO_3), Lithium Borate (LiBO_3) periodically poled lithium niobate (PPLN), periodically poled lithium tantalate (PPLT) MgO:PPLN, KTP, PPKTP, RTA, BBO, MgO:LN, KTA, and PPRTA.

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The laser of claim ~~19~~ wherein the surface that has been modified to enhance the etalon effect has been polished.

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The laser of claim ~~19~~ wherein the surface that has been modified includes a coating.

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The laser of claim ~~23~~ wherein the coating includes a metallic or a dielectric material.

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The laser of claim ~~19~~, further comprising means for tuning the etalon effect.

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The laser of claim ~~25~~ wherein the tuning means adjusts an optical thickness between the front and back surfaces of the substrate.

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The laser of claim ~~26~~ wherein the adjusting means comprises a heater element thermally coupled to the substrate.

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28. The laser of claim ~~27~~, further comprising a temperature controller coupled to the heater element.

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29. The laser of claim ~~19~~ wherein the substrate has a thickness large enough such that the substrate acts as an etalon having a free spectral range of the same order as a linewidth of the laser.

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30. The laser of claim ~~29~~ wherein the free spectral range is of order 1 GHz.

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31. The laser of claim 1 wherein the reflector is a Bragg stack, whereby the saturable reflector is a saturable Bragg reflector (SBR).

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32. The laser of claim 1, wherein the reflector includes a metallic or dielectric film.

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33. The laser of claim 1, wherein the substrate is between about 100 microns and 1000 microns thick.